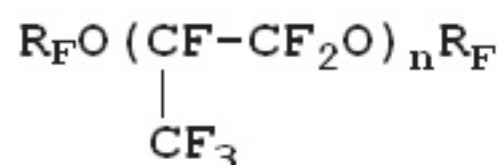


Perfluoropolyethers. Synthesis and application

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Perfluoropolyethers, generally produced through the oxidation of hexafluoropropylene, are fluorinated oligomers with alternating fluorocarbon and oxygen links. The general formula perfluoroethers is as follows:



Those oligomers are known for wide range of their boiling temperatures: from 50-70 °C to 2.320 °C at 1 mm Hg, while their freezing temperatures are about -60 °C or even lower. Perfluoropolyethers possess also a number of very unique properties [1]: high heat resistance, chemical stability in very aggressive media, incombustibility, non-toxicity, excellent dielectric characteristics, viscosity nearly unchanged in wide temperature range, excellent lubrication properties, radioimmunity, etc. The mentioned set of properties makes perfluoropolyethers applicable in various fields of modern industry for liquid dielectrics, heat-carriers, greases and lubricants. Some properties of specific perfluoropolyether fractions are shown in table 1.

Table 1. Some properties of perfluoropolyethers

Boiling range, °C/1 mm Hg	Steam tension, torr	Viscosity, cSt	Molecular weight	Solidification temperature
80-130	10 ⁻³	5-15	1200	< -80
130-180	10 ⁻⁵	50-90	1500	~ -70
180-240	10 ⁻⁷ - 10 ⁻⁸	100-150	2500	~ -50
>240	10 ⁻¹⁰	400-700	5000	~ -40
>320	10 ⁻¹⁴	1000-1800	10 000	~ -30

The methods for the manufacture the most popular perfluoropolyethers are all based

hexafluoropropylene (**CF₃-CF=CF₂**) that is an industrially available fluoromonomer used for material in the manufacture of many fluoroplastics. The current state of perfluoropolyether technology development was preceded by worldwide research undertaken by a number of Russian, USA and Italian companies, the world leaders in this field, in [2-5] in 1970 - 1980. They have studied the possibility for perfluoropolyether manufacture starting with all kinds of fluoromonomers and using various routes: gas-phase and liquid-phase processes at various temperatures, pressures, etc. The research and development of perfluoropolyether technology was complicated by the necessity of certain safety conditions observance because oxidation of fluoroolefines by oxygen results in potentially explosive peroxides. Basing both on published data and our own results a process for perfluoropolyethers manufacture is now being developed at RSC "Applied chemistry" using hexafluoropropylene for initial raw material. The process is to be conducted in liquid at low temperature (below -30°C) and under UV-irradiation or under the action of elemental fluorine.

The boiling point of hexafluoropropylene (**CF₃-CF=CF₂**) is -29.1°C. The density of liquid hexafluoropropylene at different temperatures is shown in table 2.

Table 2. *Density of hexafluoropropylene at various temperatures*

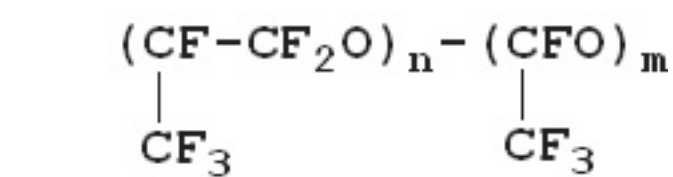
<i>Temperature, °C</i>	<i>Density, g/cm³</i>	<i>Temperature, °C</i>	<i>Density, g/cm³</i>
-40	1,565	+20	1,332
-20	1,498	+40	1,321
0	1,419	+60	1,105

Manufacture of perfluoropolyethers

The process for target "neutral" perfluoropolyethers preparation involves the steps as follows:

- low-temperature liquid-phase oxidation of hexafluoropropylene initiated either by UV-irradiation or by fluorine resulting in perfluoropolyether peroxide with fluoroanhydride terminal groups (-COF);
- stabilization of perfluoropolyether peroxide in order to eliminate peroxide groups terminal groups (-COF) through the treatment of perfluoropolyether peroxide with elemental fluorine or CoF₃, etc.;
- vacuum-fractional distillation of stabilized perfluoropolyether resulting in target fractions;
- finish sorption cleaning of perfluoropolyether.

The analysis has shown that photochemically produced perfluoropolyethers have "irregular" structure:



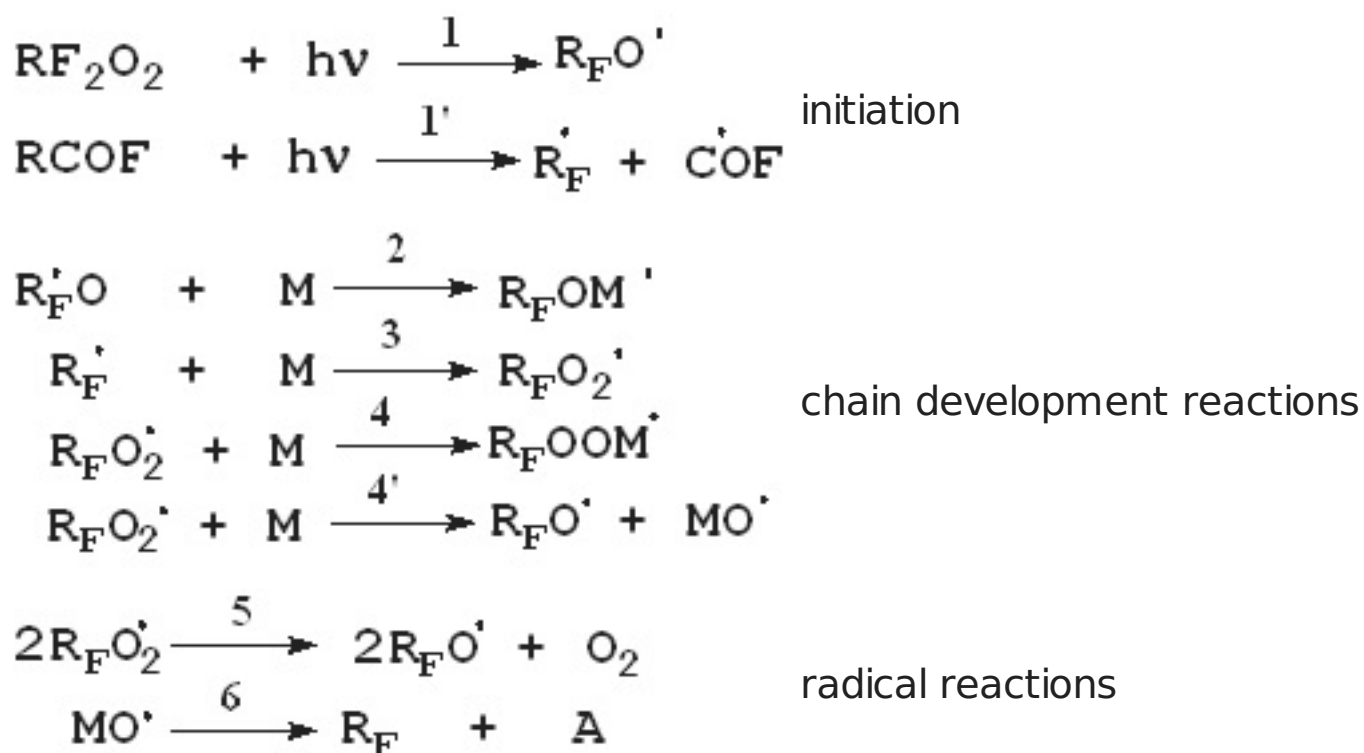
and that the low-temperature properties of such perfluoropolyethers exceed those of regular-structured perfluoropolyethers.

Study on hexafluoropropylene oxidation in liquid phase

Oxidation of hexafluoropropylene was conducted either in quartz or in a metal (stainless steel) reactor at various temperatures (-20 to -40°C). The metal reactor (steel X18H10T) was a cylinder capped with a screw cap provided with a quartz window, and equipped with a pocket for thermocouple, Gopher valve, and thermostating jacket. High-pressure mercury quartz lamp DRT-400 (220 V, AC) was used for the irradiation source. Hexafluoropropylene from a cylinder passed a column filled with silica gel and molecular sieves (to remove humidity and other impurities) and then condensed in a reactor. The reactor was cooled to the predetermined temperature and oxygen was fed into it under UV-irradiation. At the completion of the process we evacuated all gaseous reaction products, opened the reactor and poured the reaction mass into a special tank for further stabilization and the tar products isolation through vacuum distillation. Photooxidation is a complicated chain reaction with the participation of three types of radicals:

perfluoroalkyl (R_F),
perfluoroalkoxy (R_FO^\cdot),
perfluoroperoxide (R_FOO^\cdot)

The most important elemental reactions (5) are as follows:



chain interruption reactions

Here:

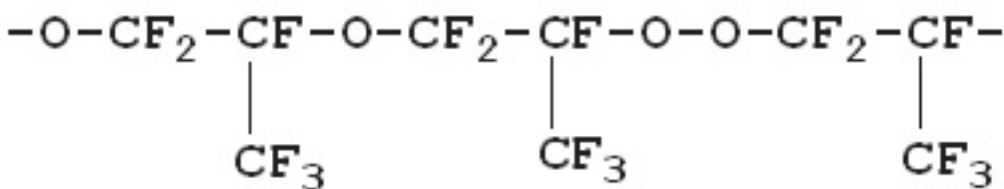
$M = C_3F_6$, $R_F = CF_3$, M ,

$A = CF_2O$, CF_3COF

Oxidation reactions start under the action of UV emission with wavelength less than 300 nm; low-pressure or medium-pressure mercury lamps are applicable for this purpose (e.g. DRT-400). Hexafluoropropylene, other fluoroolefins and their mixtures with oxygen, when free of impurities and oxidation products, do not absorb UV with wavelength more than 200 nm. That is why the reaction has got a short induction period during which fluoroolefins that are present in negligible amounts convert to some UV-absorbing substances, such as CF_3COF or peroxides, and their further photolysis results in peroxide **O-O** bonds rupture (reaction 1) and/or in acylfluoride **C-C** bonds rupture (reaction 1') followed by the formation of free radicals that initiate chain reactions between olefins and oxygen (reactions 2 -

One cannot also rule out another mechanism of the reaction active centre originat through the formation of donor-acceptor oxygen-hexafluoropropylene complexes w absorption spectra shifted to longer wavelengths. Photolysis of such complexes may res in active species able to initiate oxidation reactions. It is well known that even at temperature perfluoroalkoxy radicals tend to undergo degradation by C-C bonds, a consequently the radical decomposition (reactions 5, 6) contributes much to the ch development reactions.

According to the available test results and published data reactions of peroxyradicals is most important among all chain interruption processes [6]. Some fluorine-contair peroxyradicals thus formed may undergo recombination (reaction 5) resulting in t perfluoroalkoxyradicals that readily continue the chain. Basing on our mass-spectrosc results and in conformity with available published data [7] we made the conclusions ab the structure of hexafluoropropylene oxidation products: it contains a linear skeleton t consists of perfluoroalkyls C₃F₆, connected through oxygen atoms or through oxygen-brid bonds:



The molecules contain two types of terminal groups: alkoxy- (R_FO) and fluoroanhydride (COF) groups.

The product molecular weight depends on the hexafluoropropylene oxidation paramete at -30 — 40°C it is about 3000 - 4000. Polyether peroxides are the mane products hexafluoropropylene low-temperature liquid-phase photochemical oxidation. The produ composition depends on the process conditions, low-molecular gaseous fluorosubstan (COF₂, CF₃COF, hexafluoropropylene oxide) are also formed though in small amounts. process parameters dependence of the reaction products yields is shown.

Temperature dependence of the rate of hexafluoropropylene oxidation

Effective activation energies for fluorosubstances formation within temperature range — +25°C at oxygen pressure 7 bar are shown below in table 4.

Table 4. *Effective activation energies for fluorosubstances formation*

Substance	E effective(kcal/mole)	
-45°C — -5°C	-5°C —+25°C	
Polyether peroxide	4,43	0
Hexafluoropropylene oxide	3,05	12,6
CF ₃ COF	5,26	2,13
COF ₂	1,52	3,75

At low temperature (-35 — -5°C) only ~5% of hexafluoropropylene convert to low molecular compounds: COF₂, CF₃OF, hexafluoropropylene oxide; while >95% of original hexafluoropropylene turns into oligomer with average molecular weight ~400. Perfluoropolyether peroxide remains the main reaction product up to -15°C, the yield of low molecular products (COF₂, CF₃OF etc.) grows considerably as the temperature exceeds -15°C.

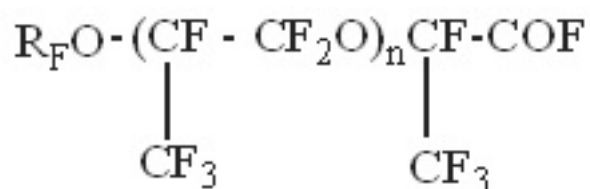
Oxygen pressure dependence of the rate of hexafluoropropylene oxidation

Our studies on the pressure dependence at -35°C and -15°C within the pressure range 0-13 bar have shown that the rate of polyetherpolyperoxide formation grows directly with oxygen pressure between 0 and 2 bar, and does not depend on oxygen pressure above 2 bar. It was also shown that as the process temperature increases the average molecular weight of perfluoropolyperoxide decreases (at +25°C, MW= 1000), and the yield of hexafluoropropylene oxide grows with temperature.

As UV-irradiation intensity grows the oligomer molecular weight goes down to constant value. The induction period of hexafluoropropylene fluorooxidation by oxygen is negligible. The reaction products (perfluoropolyether peroxides) are accumulated at the expense of their photolysis. It is well known that the main disadvantages of fluoroolefine photochemical oxidation are as follows:

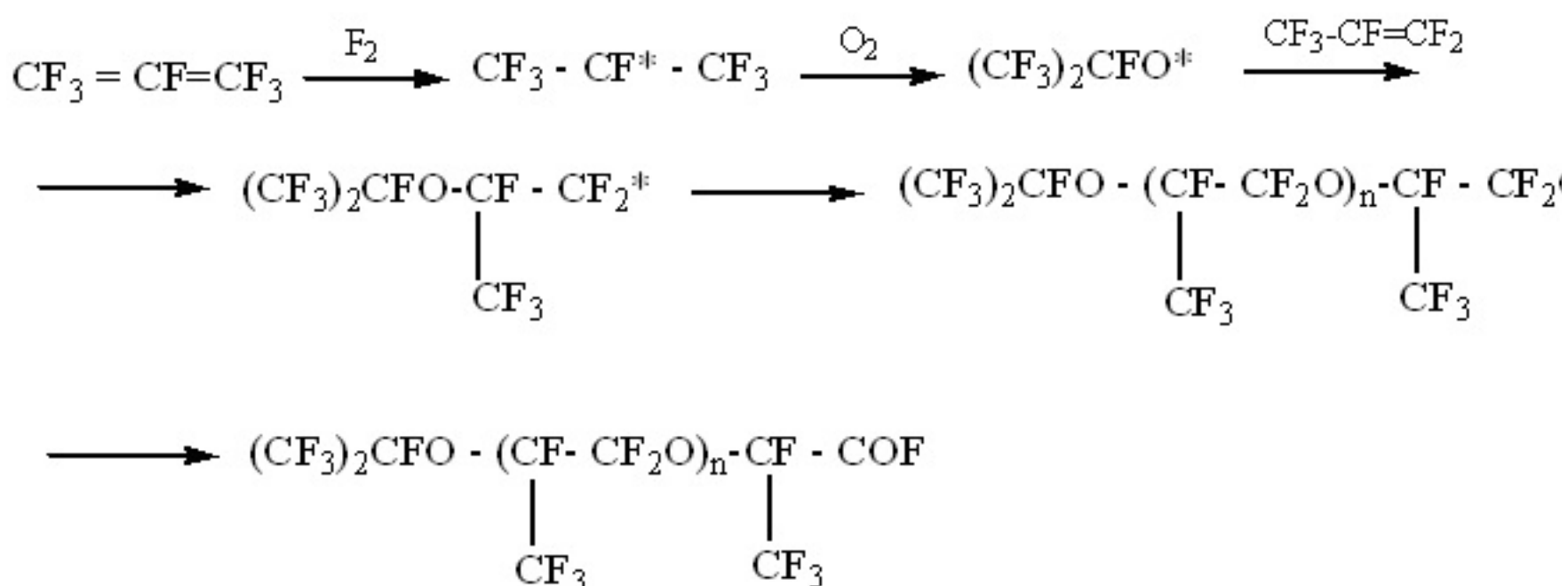
- low process productivity;
- sophisticated hardware implementation;
- low performance of UV sources, etc.

With allowance made for the above it seems more promising to apply the method of fluoroolefine/oxygen radical co-polymerization using some chemicals that undergo low temperature homolytical dissociation e.g., elemental fluorine [6]. According to NMR F¹⁹ the structure of thus produced HFP-based perfluoropolyethers is as follows:



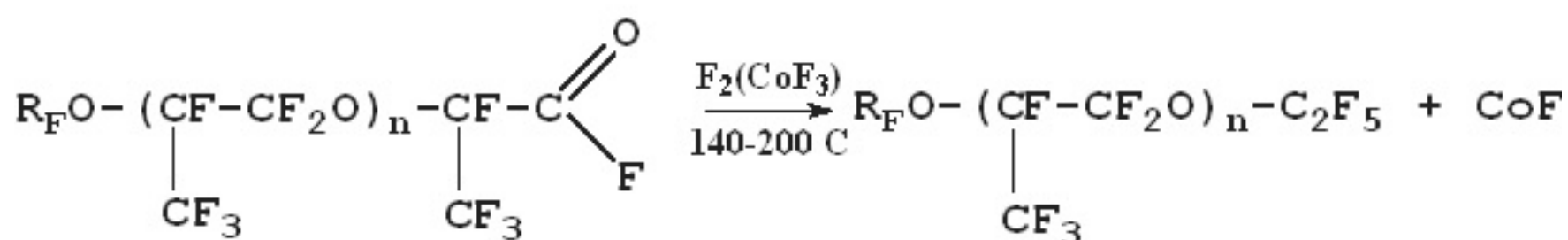
here: R_F=CF₃, (CF₃)₂CF-

It is typical for chemical fluorine-initiated processes that their products in fact do not involve neither fluoroformate nor difluoromethylene oxide groups those being, however, mandatory in photochemical oxidation products. It is anticipated that chemical fluorine-initiated hexafluoropropylene/oxygen co-polymerization occurs according to as follows:



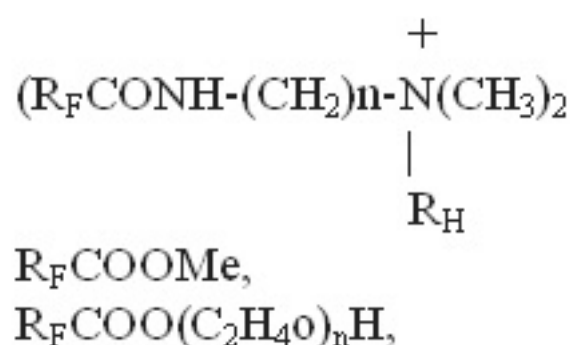
In the case of chemical fluorine-initiated hexafluoropropylene/oxygen co-polymerization production of difluorophosgene (COF_2) is rather small (0.01-0.2 mole/mole perfluoropolyether) that is ten times less than in photochemical process. A peculiarity of process chemical initiation is the absence of inhibition effects due to the reaction by-product (COF_2 , CO , CO_2 , CF_3OF etc.).

Unlike it, in the case of photochemical hexafluoropropylene/oxygen oxidation by-product completely inhibit co-polymerization process if their concentration in gas phase exceeds 3% by volume. However, chemical initiation of hexafluoropropylene/oxygen co-polymerization requires strict compliance with the process parameters. Fluorine slippage can result in self-ignition and monomer combustion in oxygen medium. In this specific case the choice of method for perfluoropolyether manufacture was dictated both by the safety considerations and by hardware implementation possibilities for the process of hexafluoropropylene/oxygen co-polymerization. Fluoroanhydride group from perfluorooligoethers produced hexafluoropropylene/oxygen co-polymerization is eliminated on exposure to elemental fluorine, CoF_3 or other fluorinating agent:



The reaction results in neutral perfluoropolyethers.

Starting from fluoroanhydrides of perfluoropolyether acids a range of efficient fluorinated surfactants was prepared: cationogenic, anionogenic, non-ionogenic [7]



Those surfactants have found many applications as components of fire-fighting foams (products fire extinguishing), oil additives, lubricants, diesel fuels, addition agents decrease

friction and improving performance of various machines, mechanisms and other techn devices.

References:

1. V.A. Ponomarenko, S.P. Krukovskij, Ftorsoderzhashchie geterotsennye polimery, M., Nauka, 1973 g.
2. D.Sianesi, A.Pasetti. J. Org. Chem, 31, 2312 (1966)
3. D.Sianesi, A.Pasetti. J. Am. Chem. Soc. Polymer. Preprints, 1971. V. 2, N 1, P411.
4. J.A.Hovard, K.Ingold. San. J. Chem, 1965, V. 43, 2729.
5. .T.Heiklen, V.Kaight, J. Phys. Chem, 1965, V. 69, N 7, 2484.
6. N. A. Ryabinin i dr., Patent RU 2046127, 1993.
7. N. A. Ryabinin, B. N. Maksimov, Patent RU 2069673, 1995.